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PATENT

Customer No. 22,852

Attorney Docket No. 04329.2199

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Kenro NAKAMURA, et al.

Application No.: 09/453,831

Filed: December 2, 1999

For: POLISHING METHOD AND
POLISHING LIQUID

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) Group Art Unit: 1765
)
) Examiner: Umez-Eronini, Lynette T.
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Assistant Commissioner for Patents
Washington, DC 20231

Sir:

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AMENDMENT

In response to the December 12, 2002 Office Action, with a period for response extending through March 12, 2003, Applicants amend the application as follows, and request the Examiner's reconsideration in view of the following remarks:

IN THE CLAIMS:

Please amend claims 17 and 22, and add new claims 23 – 26 as follows:

17. (Twice Amended) A polishing method comprising:

preparing a first polishing liquid containing tetravalent cerium ions in a first

concentration;

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FINNEGAN
HENDERSON
FARABOW
GARRETT &
DUNNER LLP

1300 I Street, NW
Washington, DC 20005
202.408.4000
Fax 202.408.4400
www.finnegan.com